



Docket No.: A8319.0058/P058  
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:  
Masahiko Ando et al.

Application No.: 09/902,170

Confirmation No.: 8805

Filed: July 11, 2001

Art Unit: 2823

For: THIN FILM TRANSISTOR, LIQUID  
CRYSTAL DISPLAY AND  
MANUFACTURING METHOD THEREOF

Examiner: K. D. Nguyen

ENTERED  
By  
RCE  
9/13/05  
V/S

AMENDMENT AFTER FINAL ACTION (37 C.F.R. SECTION 1.116)

MS AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

**INTRODUCTORY COMMENTS**

In response to the Office Action dated March 16, 2005, finally rejecting claims 1-9, 11-21, 23-32, 34, 50-58, 60-70, 72-81 and 83, please amend the above-identified U.S. patent application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 16 of this paper.

For the reasons set forth above, claims 1-8, 13-20, 24-31, 50-57, 62-69 and 74-80 are patentable over AAPA in view of Tsujimura. Washizuka is cited in the rejection for teaching simultaneously diffusing and annealing a capping layer. This is not related to the arguments presented above. Washizuka does not overcome the deficiencies in AAPA or Tsujimura. For at least these reasons, claims 9, 11-13, 21, 23, 24, 32, 34, 58, 60-62, 70, 72, 73, 81 and 83 should be allowable for reasons similar to those given above in connection with claim 1, and for other reasons.

In view of the above amendment, applicant believes the pending application is in condition for allowance.

Dated: July 29, 2005

Respectfully submitted,

By 

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